

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application	)	PATENT APPLICATION
	)	
Inventor(s): S. Brad Herner <i>et al.</i>	)	Art Unit: 1762
	)	
Appl. No.: 10/769,047	)	Examiner: Chen, Bret P.
	)	
Filed: January 30, 2004	)	Docket No. SAND-01138US0
	)	(formerly MA-100-I)
Title: LOW TEMPERATURE, LOW-RESISTIVITY HEAVILY DOPED <u>P-TYPE POLYSILICON DEPOSITION</u>	)	<u>Customer No. 64948</u>

Assistant Commissioner for Patents  
PO Box 1450  
Alexandria VA 22313-1450

**RESPONSE TO NON-FINAL OFFICE ACTION**

This paper is filed in response to the non-final Office Action of December 28, 2006, concerning the above-referenced patent application.

A COMPLETE LISTING OF CLAIMS begins on page 2 of this paper.

A DISCUSSION OF CLAIM AMENDMENTS begins on page 5 of this paper.

REMARKS begin on page 6.

A petition for a one-month extension of time under 37 CFR 1.136, together with the appropriate fee, is also submitted herewith.